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## Quantitative analysis of atomic disorders in full-Heusler Co<sub>2</sub>FeSi alloy thin films using x-ray diffraction with Co $K\alpha$ and Cu $K\alpha$ sources

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The authors developed a new analysis technique for atomic disorder structures in full-Heusler alloys using x-ray diffraction (XRD) with Co  $K\alpha$  and Cu  $K\alpha$  sources. The technique can quantitatively evaluate all the atomic disorders for the exchanges between X, Y, and Z atoms in full-Heusler  $X_2YZ$ alloys. In particular, the technique can treat the DO3 disorder that cannot be analyzed by ordinary Cu  $K\alpha$  XRD. By applying this technique to full-Heusler Co<sub>2</sub>FeSi alloy thin films formed by rapid thermal annealing (RTA), RTA-temperature  $(T_A)$  dependence of the atomic disorders was revealed. The site occupancies of Co, Fe, and Si atoms on their original sites were 98%, 90%, and 93%, respectively, for the film formed at  $T_A$ =800 °C, indicating that the RTA-formed Co<sub>2</sub>FeSi film had the L2<sub>1</sub> structure with the extremely high degree of ordering. © 2010 American Institute of Physics. [doi:10.1063/1.3350914]

Half-metallic ferromagnets (HMFs)<sup>1</sup> are very attractive for spintronic devices, such as magnetic tunnel junctions<sup>2,3</sup> and spin transistors, <sup>4,5</sup> owing to their perfect spin polarization of 100% at the Fermi energy. In particular, Co-based full-Heusler alloys, e.g.,  $Co_2FeSi$  (CFS)<sup>6</sup>,  $Co_2FeSi_{1-x}Al_x$  $(CFSA)^7$ ,  $Co_2MnSi$  (CMS), and  $Co_2CrAl$  (CCA), are promising as a HMF material, since they show the halfmetallicity even at higher temperatures over room temperature. The half-metallicity of full-Heusler alloys is very sensitive to atomic disorders in their crystal structure [that is the  $L2_1$  structure shown in Fig. 1(a)]. 9,10 X-ray diffraction (XRD) technique has been commonly used to evaluate their disordered structures. 11–16 However, XRD analysis with an ordinary Cu  $K\alpha$  source cannot distinguish a disordered structure related to the exchange between Co and Fe (Mn, or Cr) atoms from the  $L2_1$  structure, in which the hidden disorder is the so-called *DO*3 disorder [shown in Fig. 1(b)]. In general, detection and evaluation of the DO3 disorder required special measurement setups such as neutron diffraction, 17 synchrotron XRD, <sup>18,19</sup> and nuclear magnetic resonance. <sup>20</sup> In this study, we developed a quantitative analysis technique of the DO3 disorder and the other atomic disorders in full-Heusler alloys using a conventional XRD system with Co  $K\alpha$  (0.179) nm) and Cu  $K\alpha$  (0.154 nm) sources. Applying this technique to full-Heusler CFS alloy thin films<sup>6,16</sup> formed by rapid thermal annealing (RTA), we determined the atomic disorders for the exchanges between Co, Fe, and Si atoms in the films quantitatively.

The  $L2_1$  structure of full-Heusler  $X_2YZ$  alloys consists of eight stacked body-centered cubic (bcc) lattices, and the corner sites of each bcc lattice are occupied by X atoms and the

body-centered sites are occupied by Y and Z atoms regularly, as shown in Fig. 1(a). In the case of CFS, X, Y, and Z are Co, Fe, and Si atoms, respectively. Full-Heusler alloys also have disordered structures referred to as the B2 and A2 structures. In the B2 structure, the YZ sublattice is disordered. For CFS, the exchange between Fe and Si atoms in the L2<sub>1</sub> lattice results in the B2 structure. The A2 structure has no ordered sublattice, i.e., both the X and YZ sublattices are disordered. For CFS, the exchanges between Co, Fe, and Si atoms cause the A2 structure. In many cases, these disordered structures are identified by XRD analysis. XRD for full-Heusler alloys can be divided into odd superlattice diffraction, even superlattice diffraction, and fundamental diffraction. The odd superlattice diffraction is defined by the index relation of h, k, and l=odd numbers, e.g., (111), which can be observed when the  $L2_1$  structure is formed. The even superlattice diffraction is defined by h+k+l=4n+2, e.g., (200), which appears for the B2 and  $L2_1$  structures. The fundamental diffraction appears in the case of h+k+l=4n, e.g., (220), which is independent of the ordering structures, i.e., this diffraction can be observed even for the A2 structure. In general, degrees of order of the  $L2_1$  and B2 structures can be semiquantitatively evaluated by the odd and even superlattice diffraction intensities using a hypothesis introduced by Webster. 11-16

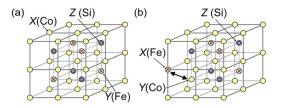


FIG. 1. (Color online) (a) Schematic illustration of the L2<sub>1</sub> structure of full-Heusler alloys. (b) Schematic illustration of the DO3 disorder.

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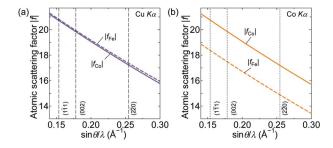


FIG. 2. (Color online) Atomic scattering factors of Co and Fe atoms,  $f_{\rm Co}$  and  $f_{\rm Fe}$ , as a function of  $\sin \theta/\lambda$  for (a) Cu  $K\alpha$  and (b) Co  $K\alpha$ , where  $\theta$  and  $\lambda$  are scattering angle of x-ray and incident x-ray wavelength, respectively.

However, it is well recognized for full-Heusler CFS (and related CFSA) alloys that commonly used XRD analysis with an ordinary Cu  $K\alpha$  source cannot detect a disordered structure caused by the exchange between Co and Fe atoms (that is the DO3 disorder). This is because the atomic scattering factor  $(f_{Co})$  of Co is almost the same as that  $(f_{Fe})$  of Fe for the Cu  $K\alpha$  source, <sup>14,20</sup> as shown in Fig. 2(a), and thus superlattice diffraction intensities for the DO3-disordered structure cannot be distinguished from those for the fully ordered L2<sub>1</sub> structure. Since the DO3 disorder is a kind of the A2 disorder that would strongly degrade the halfmetallicity of full-Heusler alloys, detection and evaluation of the DO3 disorder are highly important. Nevertheless, XRD study for the DO3 disorder in full-Heusler alloys has not progressed owing to the above-described difficulty in its detection. It should be noted that although the Webster method is widely used for XRD analysis for full-Heusler CFS alloys, <sup>11–16</sup> the amount of the exchange between Co and Fe atoms (DO3 disorder) is treated to coincide with that of the exchange between Co and Si atoms. 11-13,16 The similar issue of the DO3 disorder has also arisen for other full-Heusler alloys such as CMS and CCA.

The atomic scattering factors ( $f_{\text{Co}}$  and  $f_{\text{Fe}}$ ) of Co and Fe for Co  $K\alpha$  are different due to x-ray anomalous scattering, <sup>15</sup> as shown in Fig. 2(b). Therefore, superlattice diffraction intensities for Co  $K\alpha$  can well reflect the DO3 disorder. Our quantitative approach using Co  $K\alpha$  and Cu  $K\alpha$  XRD is based on the physical model proposed by Niculescu *et al.* <sup>21</sup> (hereafter, this model is referred to as the NRBB model.) In this model, the disorders in full-Heulser alloys are expressed by three disorder parameters,  $\alpha$ ,  $\beta$ , and  $\gamma$ . Table I shows the expression of disordered structures using  $\alpha$ ,  $\beta$ , and  $\gamma$ , in which  $\alpha$  is defined as the number of Fe(Si) atoms occupying on Z(Y) sites per a Co<sub>2</sub>Fe<sub>1</sub>Si<sub>1</sub> unit, which represents the exchange between Fe and Si atoms (i.e., B2 disorder),  $\beta$  is defined as the number of Co(Si) atoms on Z(X) sites per a Co<sub>2</sub>Fe<sub>1</sub>Si<sub>1</sub> unit, which represents the exchange between Co

TABLE I. Definition of the number of constituent atoms in full-Heulser  $Co_2FeSi$  alloy (in unit of a  $Co_2Fe_1Si_1$  molecule).

	X sites	Y sites	Z sites
Co	2-γ-β	γ	β
Fe	γ	1-α-γ	$\alpha$
Si	$oldsymbol{eta}$	$\alpha$	$1-\alpha-\beta$

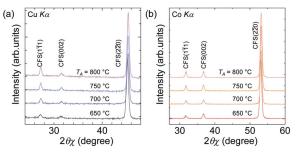


FIG. 3. (Color online) (a) In-plane XRD patterns measured with Cu  $K\alpha$  and (b) Co  $K\alpha$  for Co<sub>2</sub>FeSi films formed at  $T_A$  ranging from 650 to 800 °C.

and Si atoms (hereafter, this exchange is referred to as the A2' disorder in order to distinguish it from the A2 disorder in the Webster model  $^{11,16,17}$ ), and  $\gamma$  is defined as the number of Co(Fe) atoms on Y(X) sites per a  $Co_2Fe_1Si_1$  unit, which represents the exchange between Co and Fe atoms (DO3 disorder). Note that in the Webster framework, the A2' and DO3 disorders are treated as the identical disorder (A2 disorder) expressed by a single parameter. In the NRBB model, the perfect  $L2_1$  structure is expressed by a parameter set of  $(\alpha, \beta, \gamma) = (0, 0, 0)$ . For the B2, A2, and DO3 disordered structures, maximum  $(\alpha, \beta, \gamma)$  values are (1/2, 0, 0), (1/4, 1/2, 1/2), and (0, 0, 2/3), respectively. Using the expression of the disordered structures shown in Table I, the crystal structure factors  $^{11}F_{111}$ ,  $F_{200}$ , and  $F_{220}$  of (111), (200), and (220) diffraction can be written by

$$F_{111} \propto (1 - 2\alpha - \beta)(f_{\text{Fe}} - f_{\text{Si}}) + (\gamma - \beta)(f_{\text{Co}} - f_{\text{Fe}}),$$
 (1)

$$F_{200} \propto (1 - 2\beta)(f_{\text{Co}} - f_{\text{Si}}) + (1 - 2\gamma)(f_{\text{Co}} - f_{\text{Fe}}),$$
 (2)

$$F_{220} \propto 2f_{C_0} + f_{Fe} + f_{Si},$$
 (3)

where  $f_{\text{Co}}$ ,  $f_{\text{Fe}}$ , and  $f_{\text{Si}}$  are the atomic scattering factors of Co, Fe, and Si, respectively. These values can be taken from Ref. 22. It should be noted that the last terms in Eqs. (1) and (2) include  $\gamma$  and have the factor of difference of  $f_{\text{Co}}$ - $f_{\text{Fe}}$ . In the case of Cu  $K\alpha$ , there are few differences between  $f_{Co}$  and  $f_{Fe}$ [shown in Fig. 2(a)]. Therefore, the superlattice diffraction intensities  $[I_{111}(\propto F_{111}^2)]$  and  $I_{200}(\propto F_{200}^2)$  for Cu  $K\alpha$  does not change with variation of  $\gamma$ , since the  $\gamma$ -related terms in Eqs. (1) and (2) are eliminated. On the other hand, in the case of Co  $K\alpha$ , there exists the large difference between  $f_{Co}$  and  $f_{Fe}$ [shown in Fig. 2(b)], and thus the superlattice diffraction intensities for Co  $K\alpha$  well reflect  $\gamma$ . Using both Cu  $K\alpha$  and Co  $K\alpha$  XRD, we can obtain the following four superlattice diffraction intensities:  $I_{111}$  and  $I_{200}$  for Co  $K\alpha$ , and  $I_{111}$  and  $I_{200}$  for Cu  $K\alpha$ . In order to minimize measurement errors, the three unknown parameters of  $\alpha$ ,  $\beta$ , and  $\gamma$  were determined from these four intensities by the least square method. In our study, Rigaku SmartLab XRD system with Co  $K\alpha$  and Cu  $K\alpha$  x-ray sources was employed for these superlattice diffraction measurements.

Full-Heusler CFS alloy thin films were prepared by our developed RTA technique. <sup>6,16,23</sup> The CFS films were formed by the RTA-induced silicidation of Co/Fe layers deposited on a Si-on-insulator substrate. The experimental procedure and fundamental film structure investigated previously were described in Refs. 6 and 16 in detail. Figures 3(a) and 3(b)

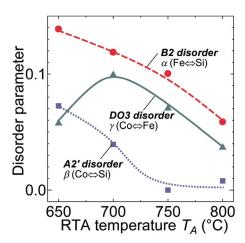


FIG. 4. (Color online) Disorder parameters,  $\alpha$  (B2 disorder),  $\beta$  (A2' disorder), and  $\gamma$  (DO3 disorder), as a function of  $T_A$ . Circles, squares, and triangles show  $\alpha$ ,  $\beta$ , and  $\gamma$ , respectively.

show the in-plane XRD patterns of the CFS films formed at RTA temperature  $T_A$  ranging from 650 to 800 °C, measured with the Cu  $K\alpha$  and Co  $K\alpha$  sources, respectively. Since the CFS thin films were (110)-oriented columnar grain (texture) structures, <sup>6,16</sup> the three important diffraction lines of (111), (002), and (220) that are perpendicular to the sample plane can be detected simultaneously by a single scan of the inplane XRD measurements. The superlattice diffraction lines of CFS(111) and CFS(002) were clearly observed for both Co  $K\alpha$  and Cu  $K\alpha$  XRD, implying a highly ordered structure. Using these four diffraction intensities, the disorder parameters were determined.

Circles, squares, and triangles in Fig. 4 show the disorder parameters  $\alpha$ ,  $\beta$ , and  $\gamma$  as a function of  $T_A$ , respectively. All the disorder parameters were relatively small values as the overall feature. Above  $T_A$ =700 °C, they decreased with increasing  $T_A$ . The film formed at  $T_A$ =800 °C (that is the highest  $T_A$  examined here) showed very small values of  $(\alpha, \beta, \gamma)$ =(0.06, 0.01, 0.04). The  $\alpha$  value was comparable to that of a bulk CFS. These results revealed that all the atoms in the CFS films tend to occupy their original sites of the  $L2_1$  structure at higher temperatures. Site occupancies of Co, Fe, and Si atoms on their original sites in the  $L2_1$  structure can be easily deduced from the disorder parameters, which were 98%, 90%, and 93%, respectively, for the CFS film formed at  $T_A$ =800 °C. This result revealed that the RTA-formed CFS film has the extremely ordered  $L2_1$  structure.

In summary, we developed a new analysis technique for atomic disorder structures in full-Heusler alloys using XRD with Co  $K\alpha$  and Cu  $K\alpha$  sources. The technique can quantitatively evaluate all the atomic disorders for the exchanges between X, Y, and Z atoms in full-Heusler  $X_2YZ$  alloys with

more precise physical model than commonly used Webster's model based on XRD with a single Cu  $K\alpha$  source. In particular, the technique can treat the DO3 disorder that cannot be analyzed by Cu  $K\alpha$  XRD. Full-Heusler CFS alloy thin films formed by RTA were analyzed by this method. RTA-temperature dependence of the atomic disorders was investigated. The site occupancies of Co, Fe, and Si atoms on their original sites were 98%, 90%, and 93%, respectively, for the CFS film formed at an RTA temperature of 800 °C. This result indicated that the RTA-formed CFS film has the extremely ordered  $L2_1$  structure.

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<sup>1</sup>R. A. de Groot, F. M. Mueller, P. G. van Engen, and K. H. J. Buschow, Phys. Rev. Lett. **50**, 2024 (1983).

<sup>2</sup>Y. Sakuraba, M. Hattori, M. Oogane, Y. Ando, H. Kato, A. Sakuma, T. Miyazaki, and H. Kubota, Appl. Phys. Lett. **88**, 192508 (2006).

<sup>3</sup>K. Inomata, S. Okamura, A. Miyazaki, M. Kikuchi, N. Tezuka, M. Wojcik, and E. Jedryka, J. Phys. D 39, 816 (2006).

<sup>4</sup>S. Sugahara, IEE Proc.: Circuits Devices Syst. **152**, 355 (2005).

<sup>5</sup>S. Sugahara, Phys. Status Solidi C 3, 4405 (2006).

<sup>6</sup>Y. Takamura, R. Nakane, H. Munekata, and S. Sugahara, J. Appl. Phys. 103, 07D719 (2008).

<sup>7</sup>H. Sukegawa, W. Wang, R. Shan, T. Nakatani, K. Inomata, and K. Hono, Phys. Rev. B **79**, 184418 (2009).

<sup>8</sup>K. Inomata, N. Tezuka, S. Okamura, H. Kurebayashi, and A. Hirohata, J. Appl. Phys. 95, 7234 (2004).

<sup>9</sup>Y. Miura, K. Nagao, and M. Shirai, Phys. Rev. B **69**, 144413 (2004).

<sup>10</sup>K. Gercsi, and K. Hono, J. Phys.: Condens. Matter **19**, 326216 (2007).

<sup>11</sup>P. J. Webster, J. Phys. Chem. Solids **32**, 1221 (1971).

<sup>12</sup>O. Gaier, J. Hamrle, S. J. Hermsdoerfer, H. Schultheiß, B. Hillebrands, Y. Sakuraba, M. Oogane, and Y. Ando, J. Appl. Phys. **103**, 103910 (2008).

<sup>13</sup>Y. Sakuraba, M. Hattori, M. Oogane, H. Kubota, Y. Ando, and T. Miyazaki, J. Magn. Soc. Jpn. 31, 338 (2007).

<sup>14</sup>Y. V. Kudryavtsev, V. A. Oksenenko, Y. P. Lee, Y. H. Hyun, J. B. Kim, J. S. Park, S. Y. Parket, and J. Dubowik, Phys. Rev. B 76, 024430 (2007).

15 A. J. Bradley and J. W. Rodgers, Proc. R. Soc. London, Ser. A 144, 340 (1934).

<sup>16</sup>Y. Takamura, R. Nakane, and S. Sugahara, J. Appl. Phys. **105**, 07B109 (2000)

(2009). <sup>17</sup>K. R. A. Ziebeck and P. J. Webster, J. Phys. Chem. Solids **35**, 1 (1974).

<sup>18</sup>B. Ravel, J. O. Cross, M. P. Raphael, V. G. Harris, R. Ramesh, and V. Saraf, Appl. Phys. Lett. 81, 2812 (2002).

<sup>19</sup>L. Basit, C. Wang, C. A. Jenkins, B. Balke, V. Ksenofontov, G. H. Fecher, C. Felser, E. Mugnaioli, U. Kolb, S. A. Nepijko, G. Schonhense, and M. Klimenkov, J. Phys. D 42, 084018 (2009).

<sup>20</sup>K. Inomata, M. Wojcik, E. Jedryka, N. Ikeda, and N. Tezuka, Phys. Rev. B 77, 214425 (2008).

<sup>21</sup>V. Niculescu, K. Raj, T. J. Burch, and J. I. Budnick, Phys. Rev. B 13, 3167 (1976).

<sup>22</sup>E. Prince, *International Diffraction Tables for Crystallography*, Vols. C and D, (Springer, Berlin, 2004).

<sup>23</sup>R. Nakane, M. Tanaka, and S. Sugahara, Appl. Phys. Lett. 89, 192503 (2006).

<sup>24</sup>S. Wurmehl, G. H. Fecher, H. C. Kandpal, V. Ksenofontov, C. Felser, H. Lin, and J. Morais, Phys. Rev. B 72, 184434 (2005).